

NANO ELECTRO MECHANICAL SYSTEMS (NEMS)

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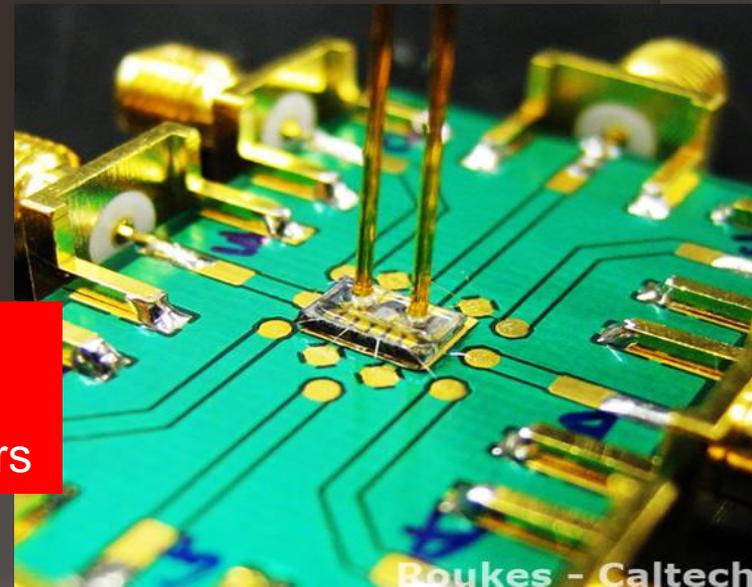
NANO Electronic Engineering Group
Electronic and Computer Engineering Department
The School of Engineering Emerging Technologies
University of Tabriz - Iran , December 2012

Outline

- ⊙ How it all began...
 - Nanoelectromechanical Systems (NEMS)
- ⊙ Basic Properties
- ⊙ Typical Problems
- ⊙ Fabrication Processes
- ⊙ Application of NEMS
- ⊙ Conclusion

How it all began...

- ◎ 1959-Richard Feynman offered a prize of \$1000 "to the first guy who makes an operating electric motor - a rotating electric motor which can be controlled from the outside and, not counting the lead-in wires, in only 1/64 inch cube."
 - stimulate new fabrication technology
- ◎ 1960-Bill McLellan, using amateur radio skills, built the motor with his hands using tweezers and a microscope
 - 2000 rpm motor weighed 250 micrograms
 - 13 parts



Nano chamber -
ultrafast gas sensing
with NEMS resonators

Nanoelectromechanical Systems (NEMS)

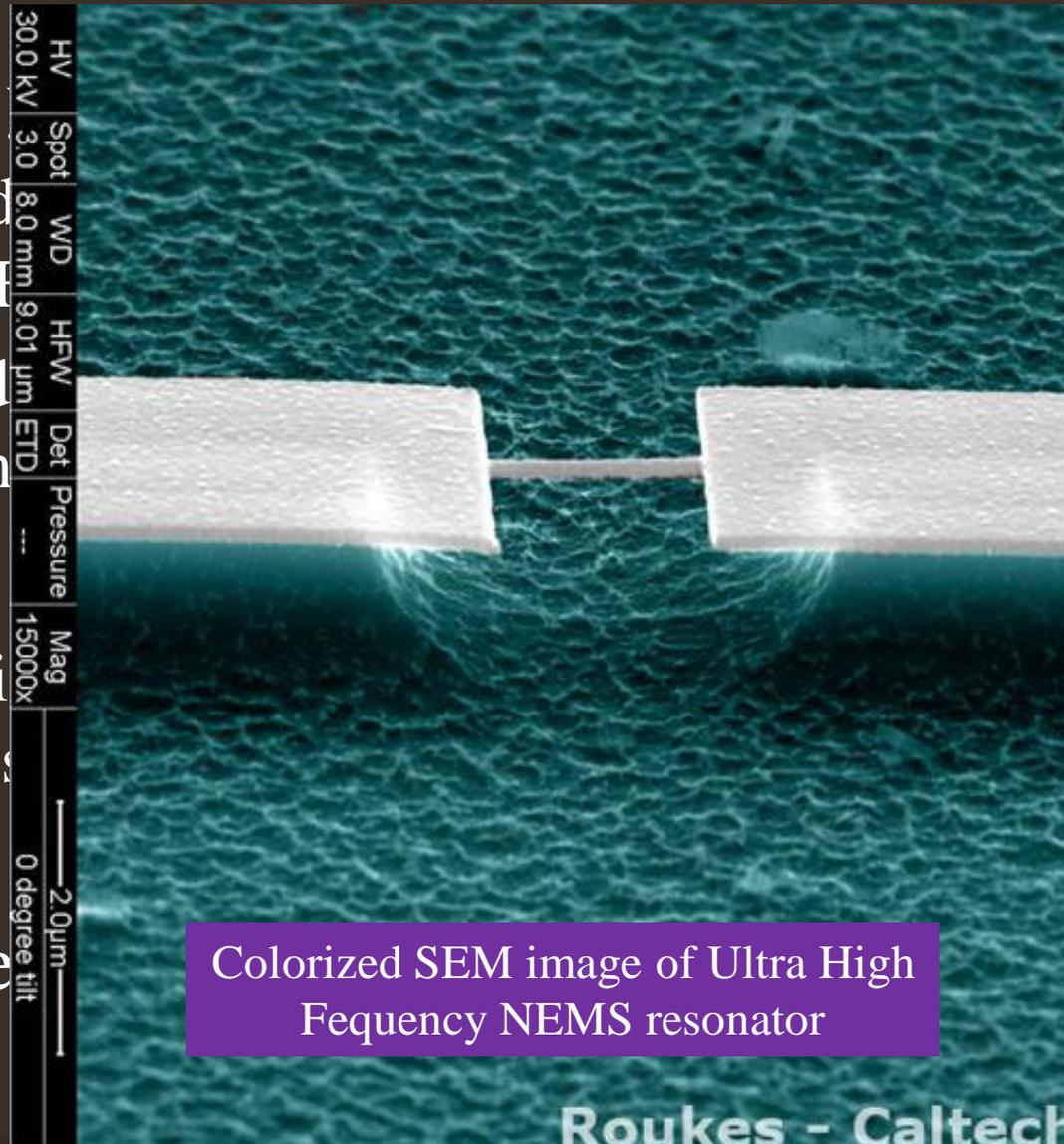
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⦿ NEMS

- devices in the nanos

⦿ Research electrome



Colorized SEM image of Ultra High Frequency NEMS resonator

(MEMS) caught

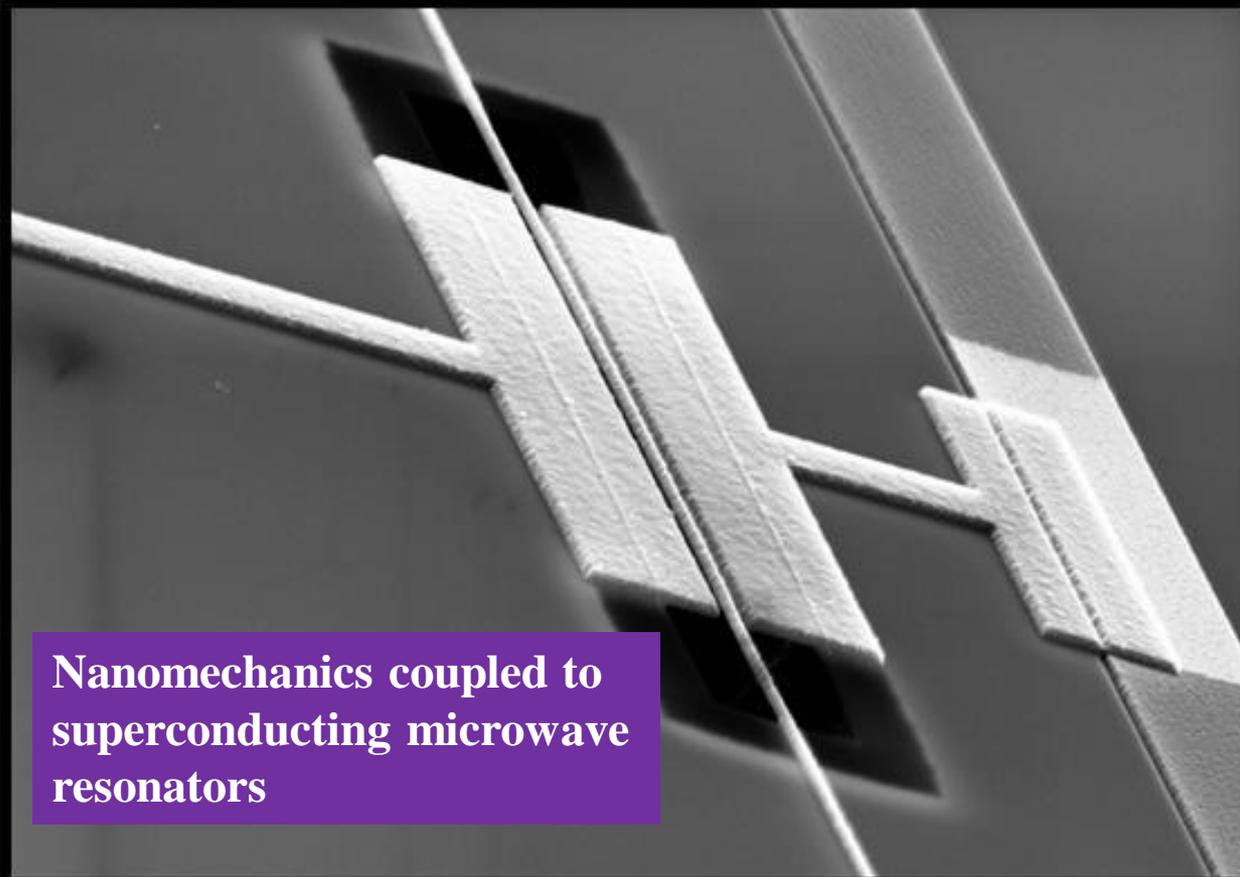
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Nanoelectromechanical Systems (NEMS)

- ⊙ Used in aerospace, automotive, biotechnology, instrumentation, robotics, manufacturing and other applications
- ⊙ Many functions
 - Sensing
 - Actuation
 - Communication

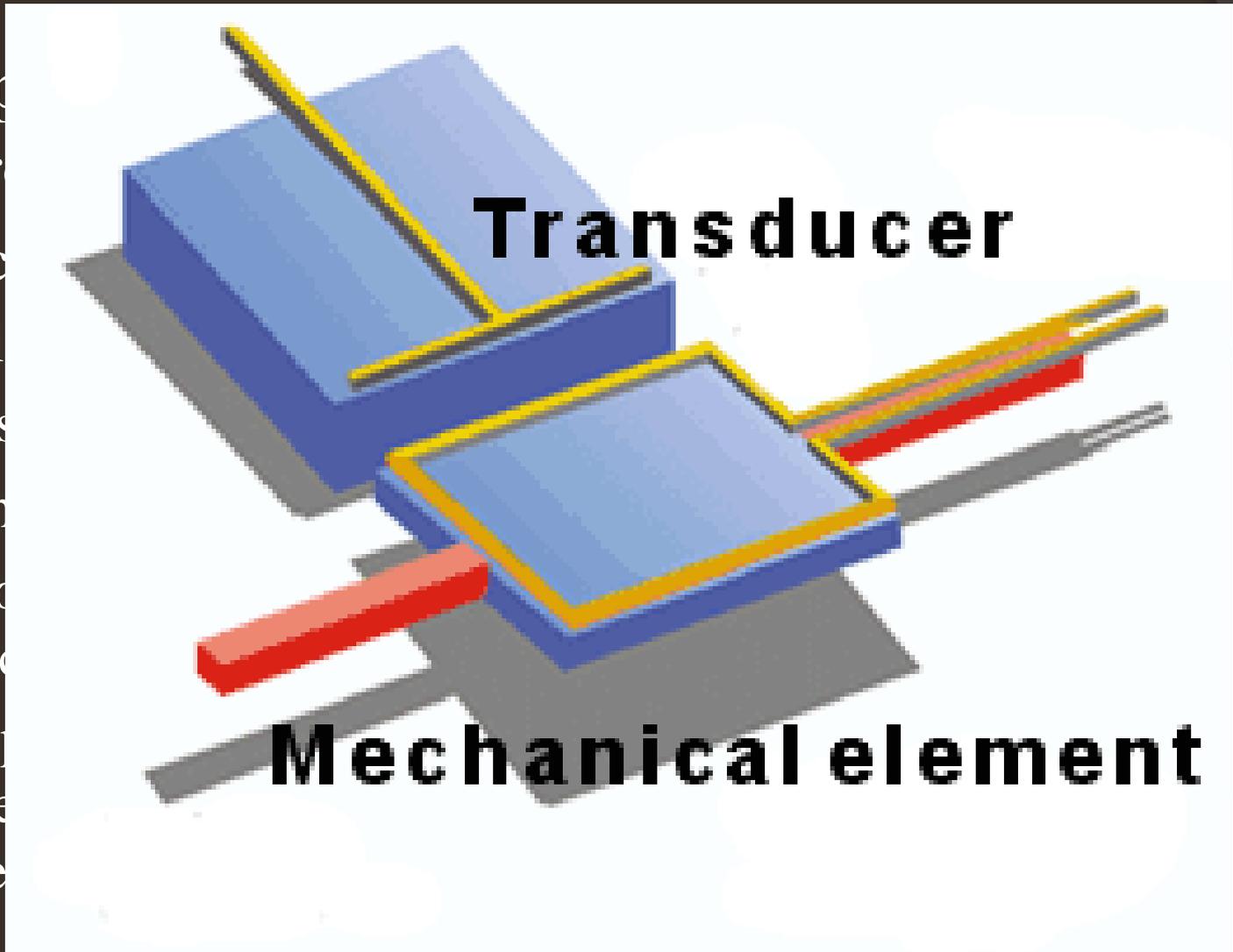


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Basic Properties

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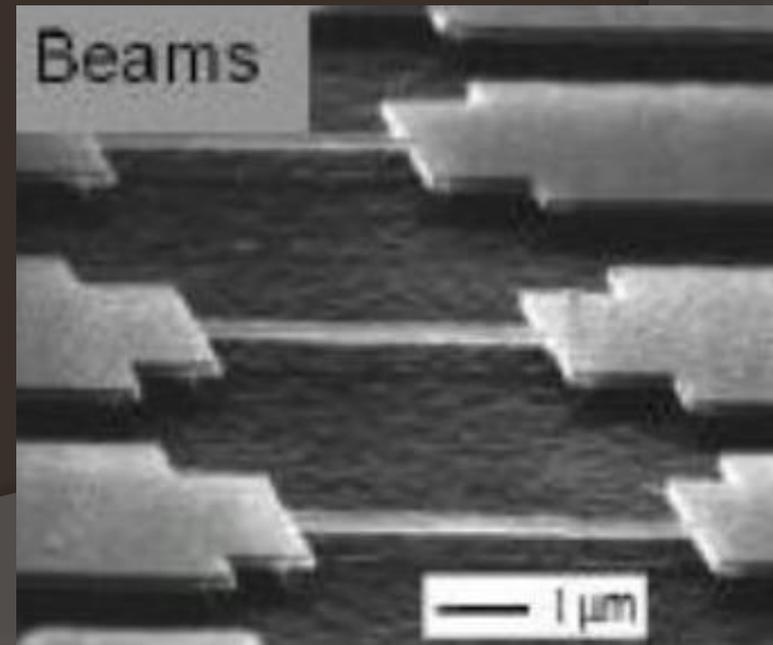


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Basic Properties

- ⊙ **Attain extremely high fundamental frequencies**
 - mechanical responsivity
- ⊙ **Dissipate very little energy**
 - Characterized by the high quality or Q factor of resonance
- ⊙ **Extremely sensitive to external damping mechanisms**
 - Crucial for building many types of sensors
 - Suppression of random mechanical fluctuations
 - Highly sensitive to applied forces

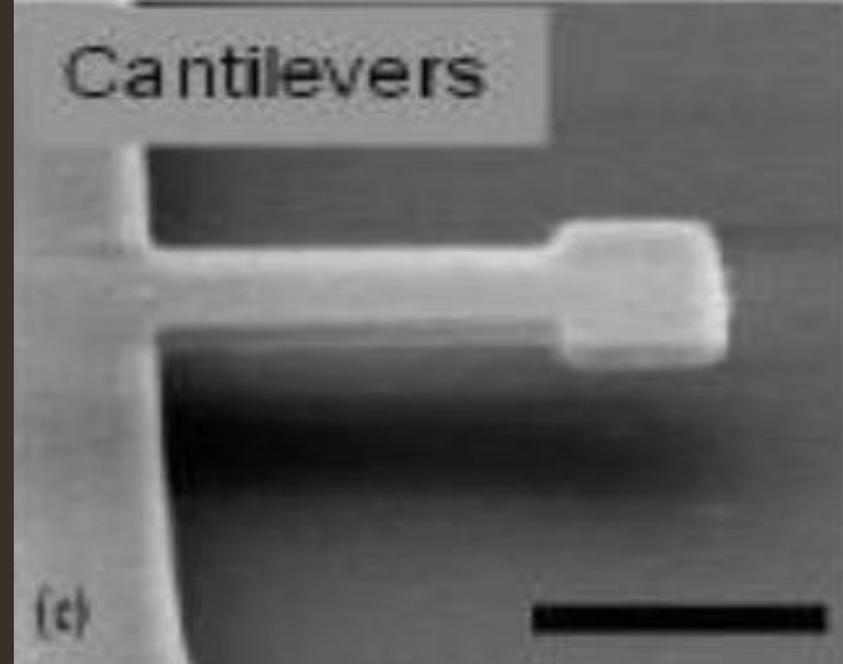


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Typical Problems

- ⦿ Great promise as highly sensitive detectors
 - mass, displacement, charge, and energy
- ⦿ An efficient, integrated, and customizable technique for actively driving and tuning NEMS resonators has remained elusive
- ⦿ Electromechanical devices are scaled downward
 - transduction becomes increasingly difficult
 - Causing the creation of finely controlled integrated systems to fail



Typical Problems

Resonator sizes continue to decrease to the nano-scale

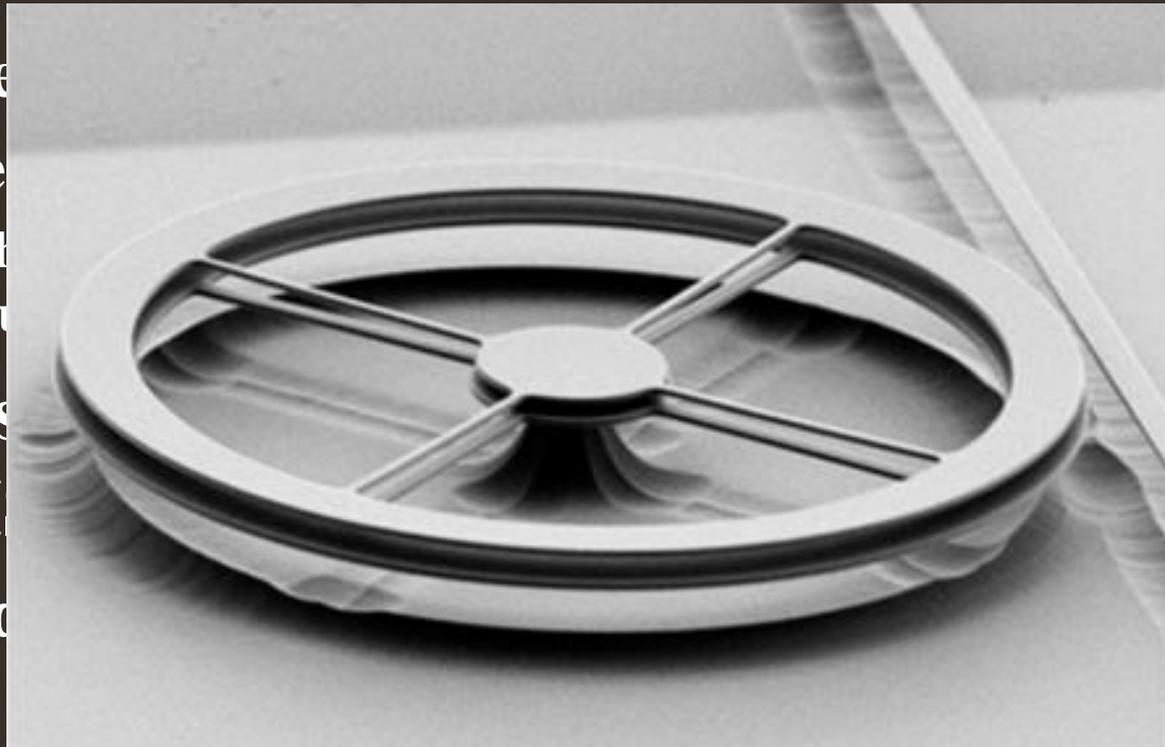
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Surfaces in NEM

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dissipation

Nanoscale resonators exert relatively strong forces on tiny particles, leading the way to important advancements in MEMS and MOMS systems

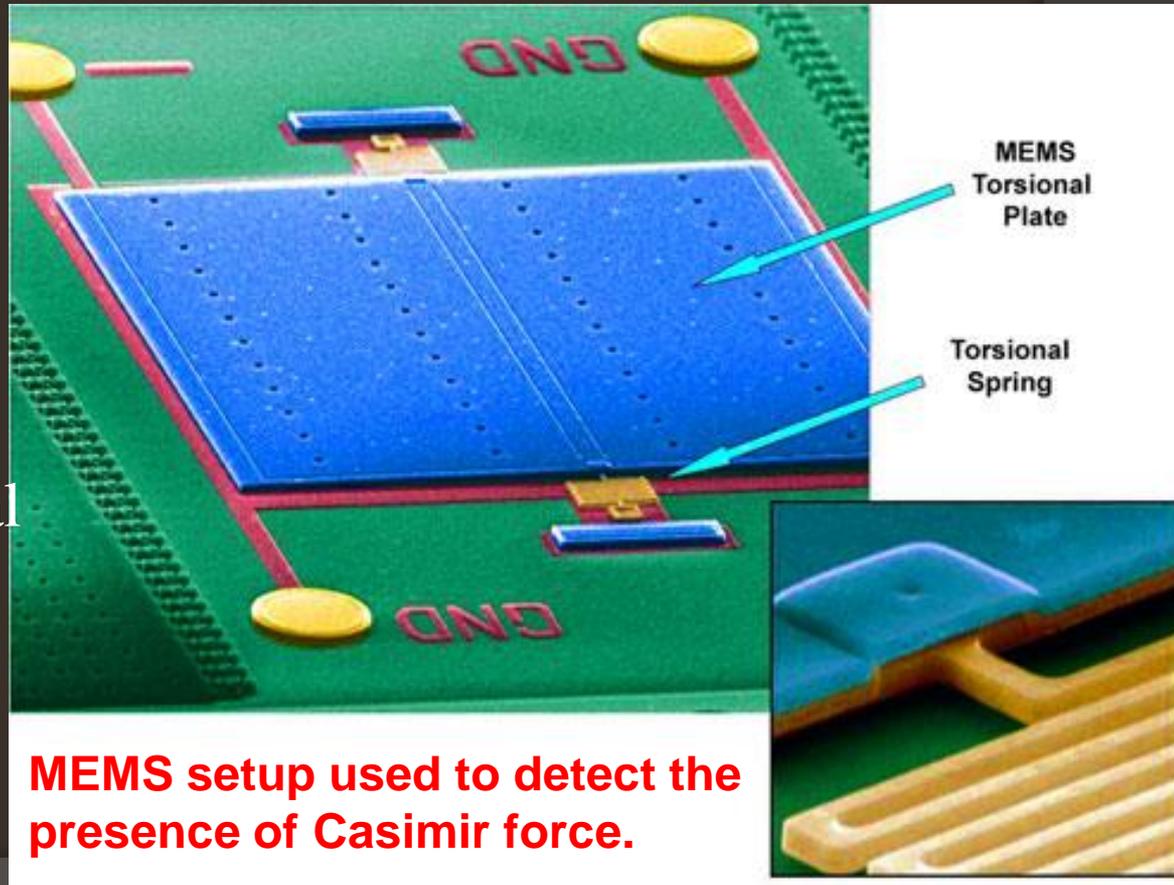
Typical Problems

◎ Casimir Effect

- quantum mechanical force that attracts objects a few nanometers apart
- Very Strong Force
 - Hard to control devices

◎ Efficient actuation

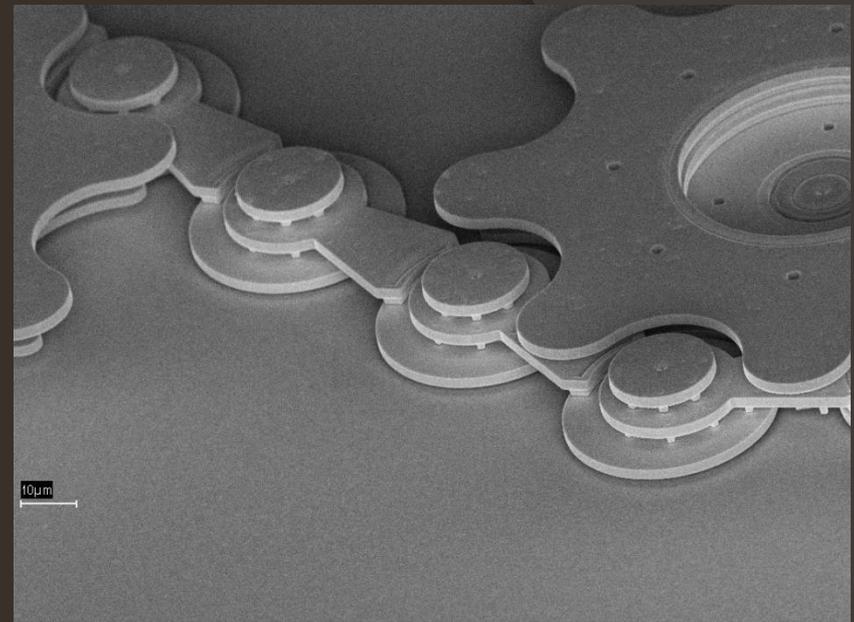
- ◎ creation of mechanical motion by converting various forms of energy rotating or linear mechanical energy



Typical Problems

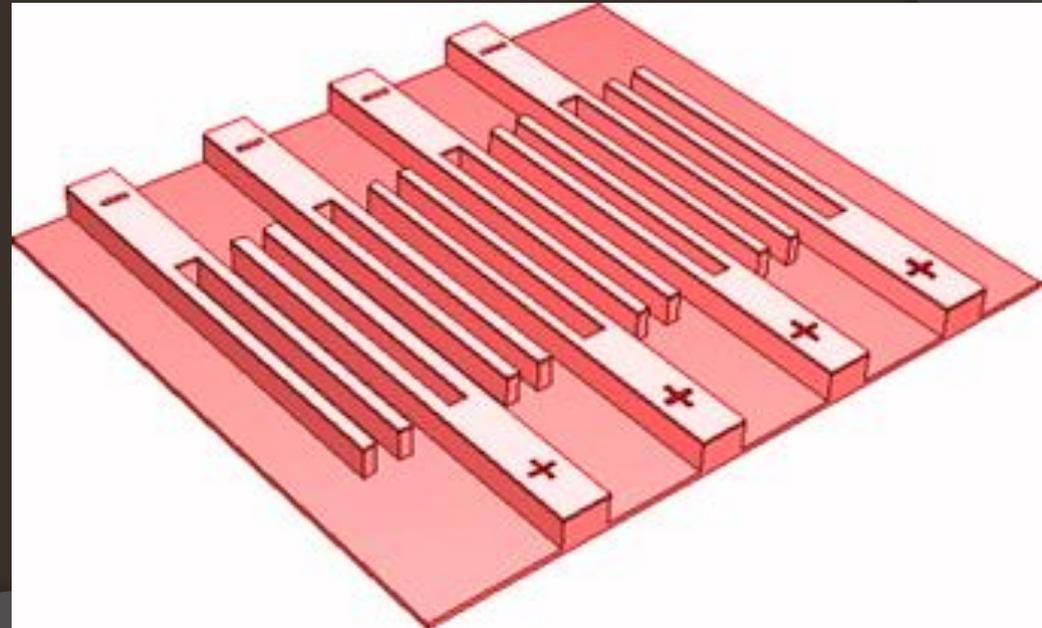
⦿ Fabrication

- Scale down effects
 - Lithography
 - Wave length limitations
- Integration with typical CMOS processes



⦿ Mass Production

- Packaging
 - Fragile
- Cost



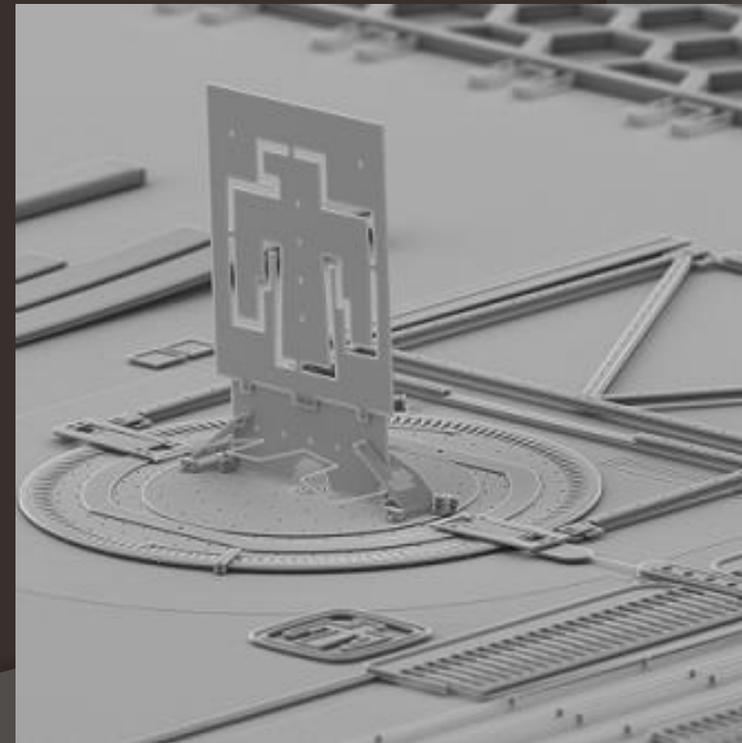
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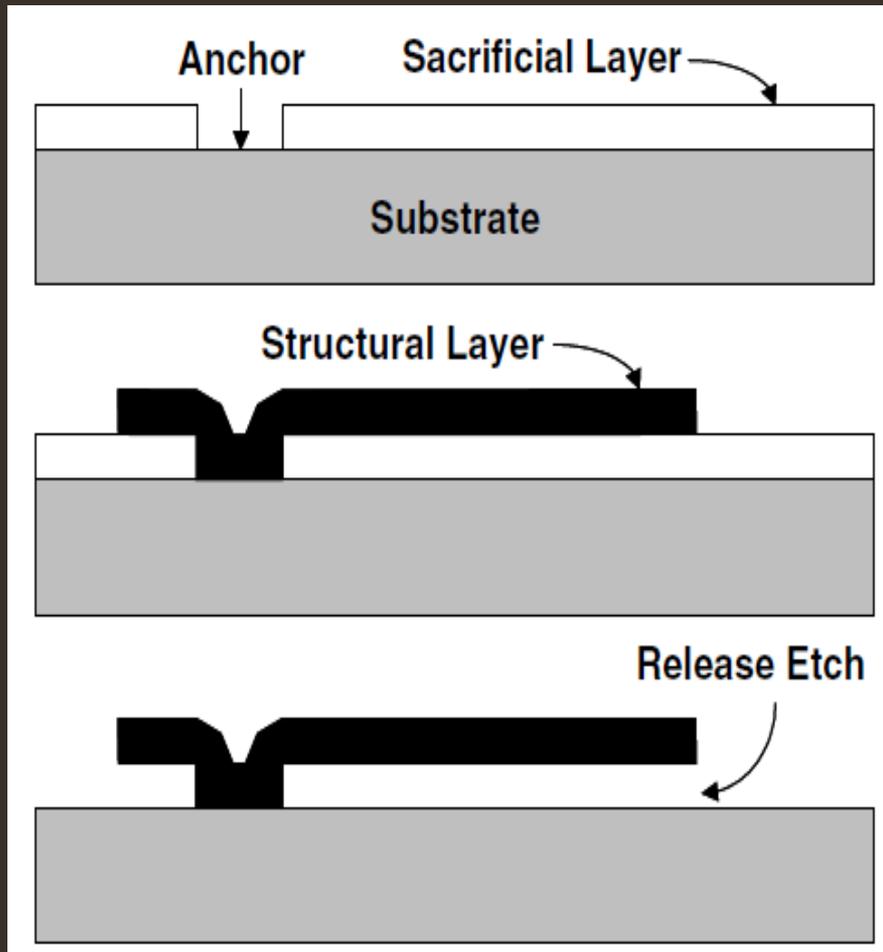
Fabrication Processes

◎ Basic Steps of Silicon Micromachining:

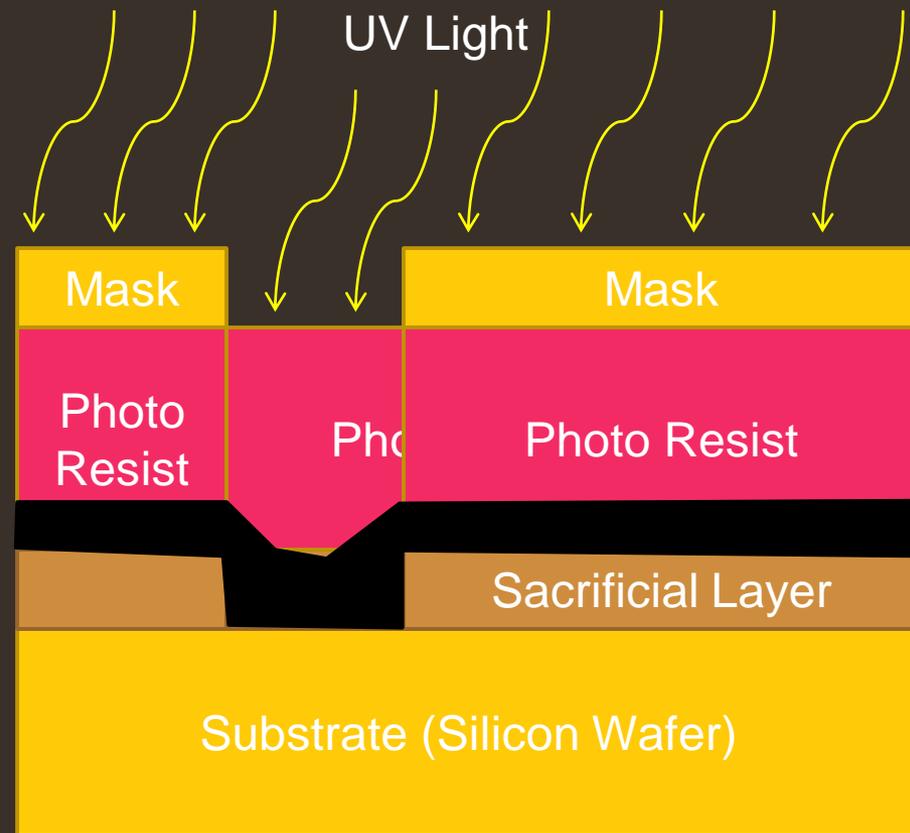
- Lithography
- Deposition of sacrificial and structural layers (PECVD, evaporation, sputtering)
- Removal of Material (patterning)
- Selective etching (RIE, Laser)
- Doping
- Bonding (Fusion, anodic)
- Planarization



Fabrication Processes

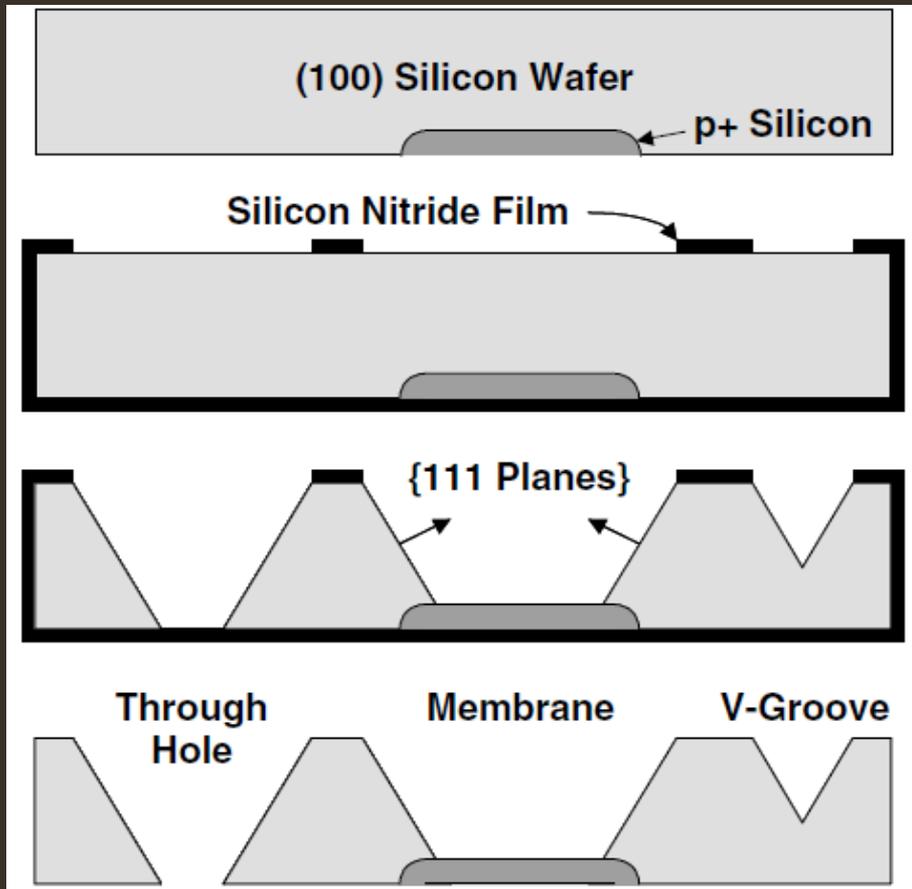


Surface Micromachining and sacrificial layer technique

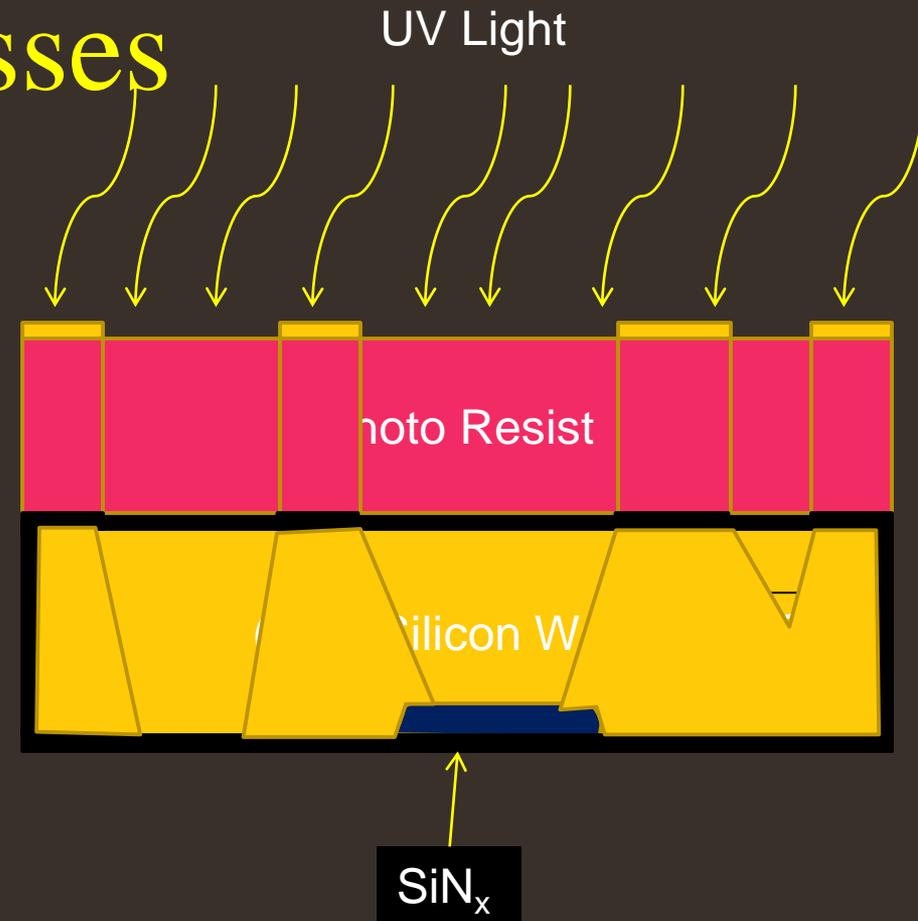


Animated Version

Fabrication Processes

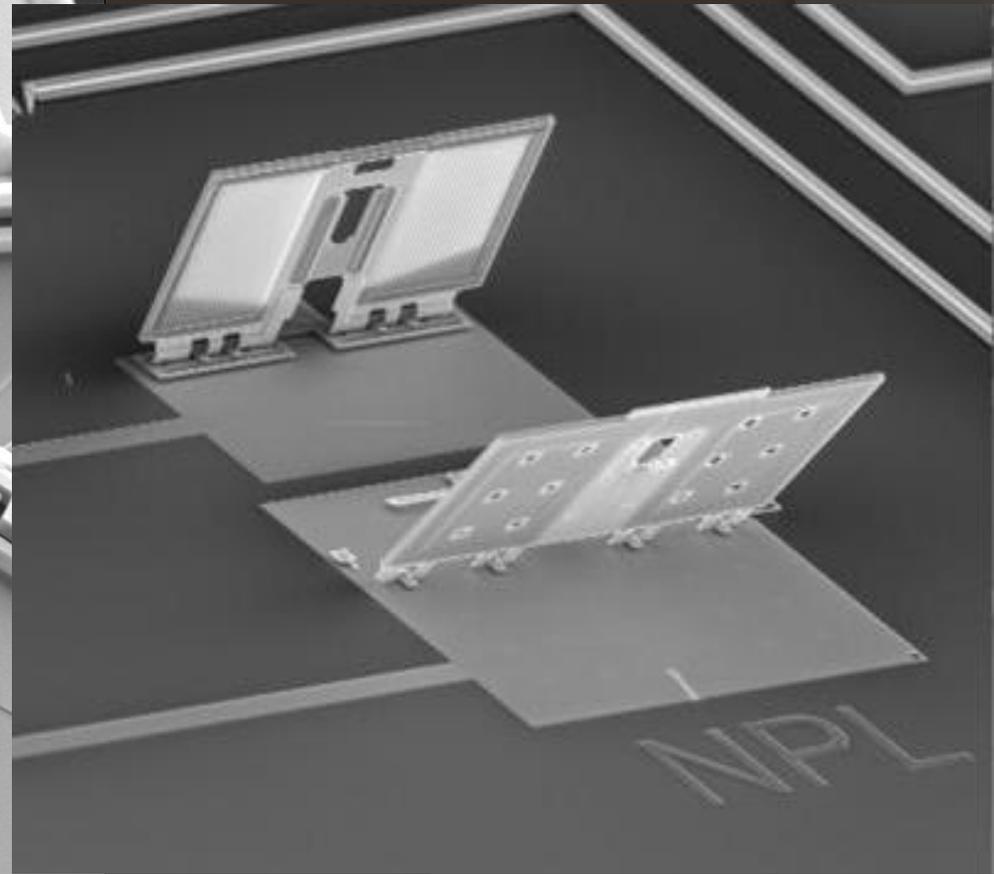


Bulk Micromachining along crystallographic planes



Animated Version

Fabrication Processes



Left image: <http://www.memx.com/>

Right Image: <http://www.npl.co.uk/science-+-technology/nanoscience/surface-+-nanoanalysis/mems-particle-detector>

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Application of NEMS:

NEM

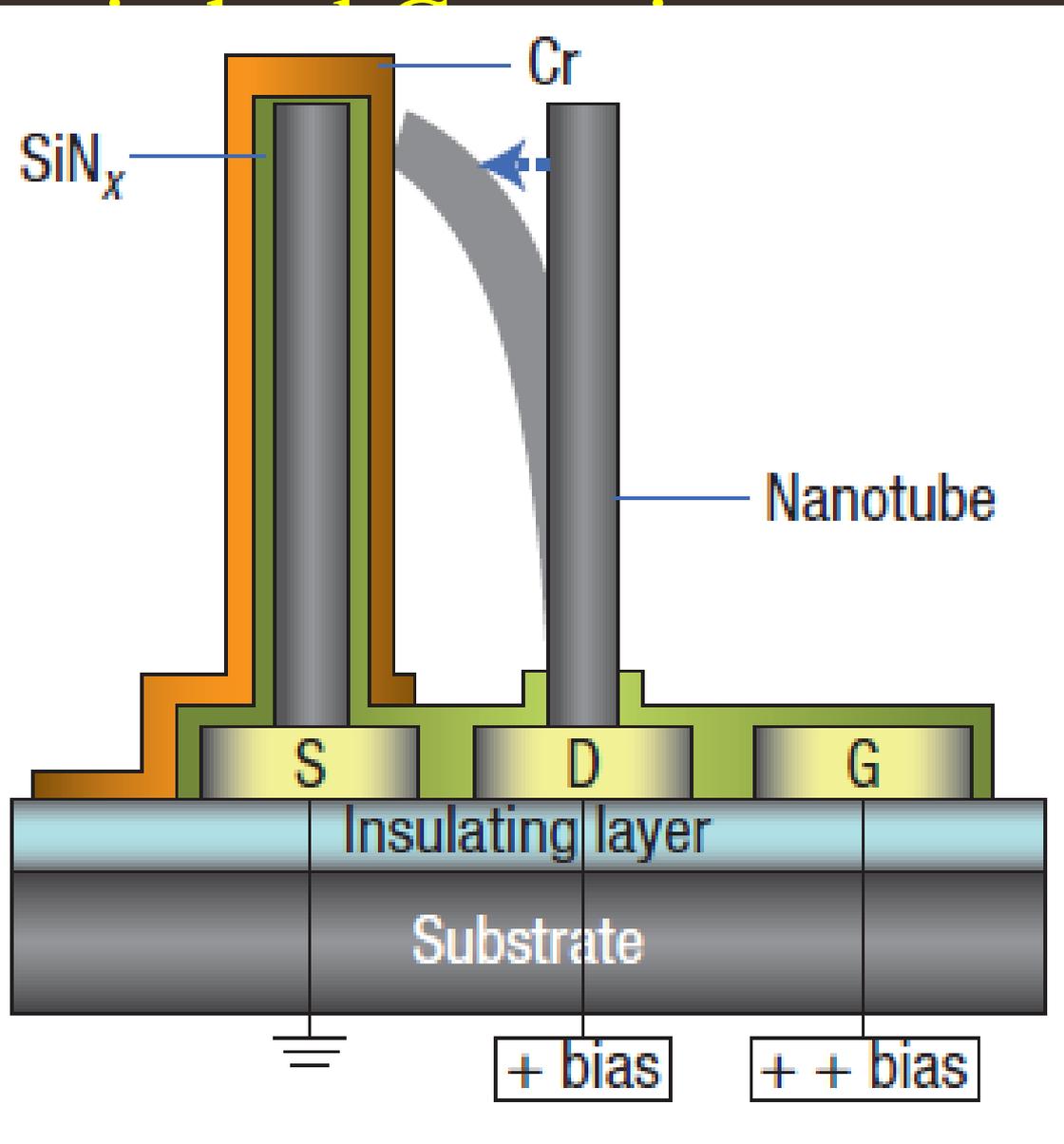
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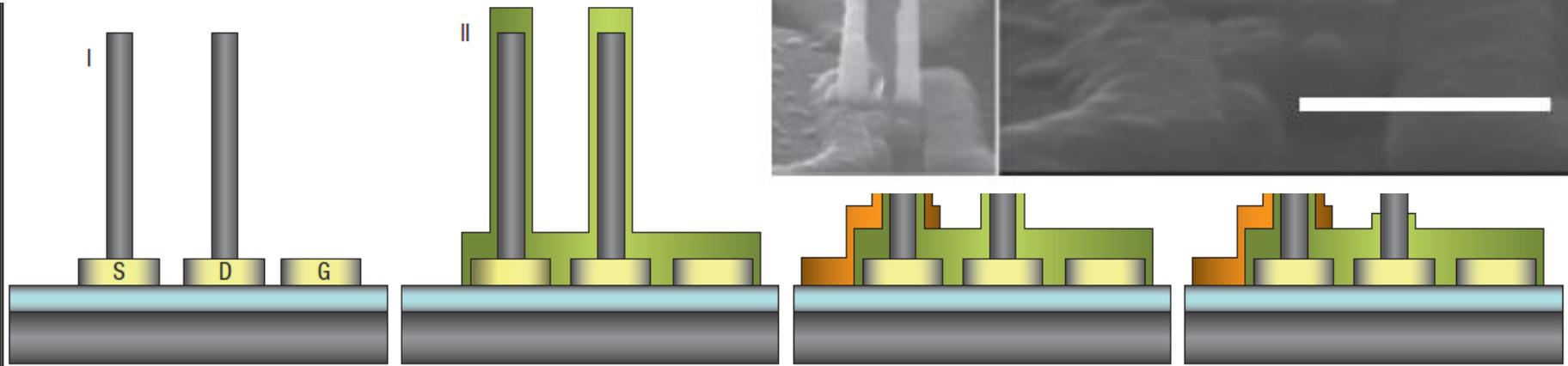
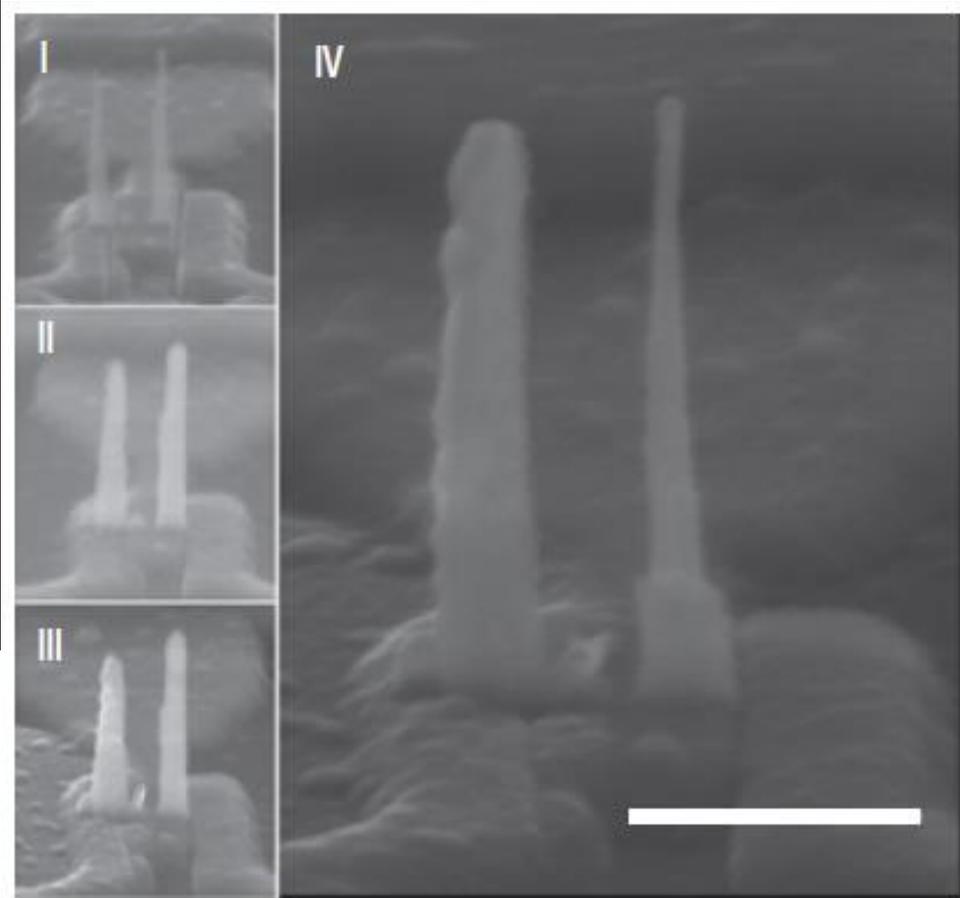
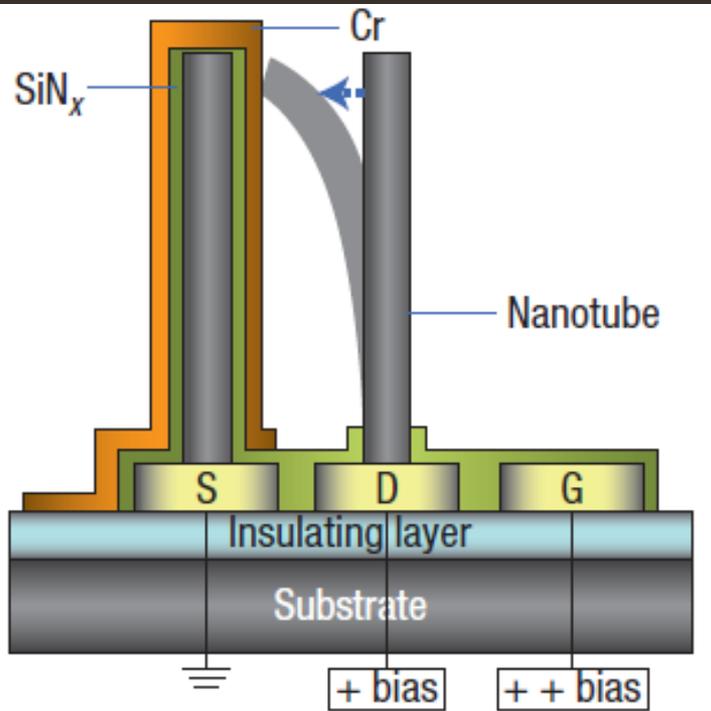
location

Application of NEMS: NEM switched Capacitor

◎ Carbon Nanotube Fabrication:

- Grown with controlled dimensions at pre-defined locations on a silicon substrate
 - Compatible with existing silicon technology
 - Vertical orientation allows for a significant decrease in cell area over conventional devices

Application of NEMS: NEM switched Capacitor



Application of NEMS: NEM switched Capacitor

- ⊙ Data has been written to the structure
 - Theoretically it is possible to read data with standard dynamic random access memory sensing circuitry
- ⊙ Simulations have been completed
 - high-k dielectrics instead of SiN_x
 - increase the capacitance to the levels needed for dynamic random access memory applications

Application of NEMS:

Self Sustaining NEM oscillator

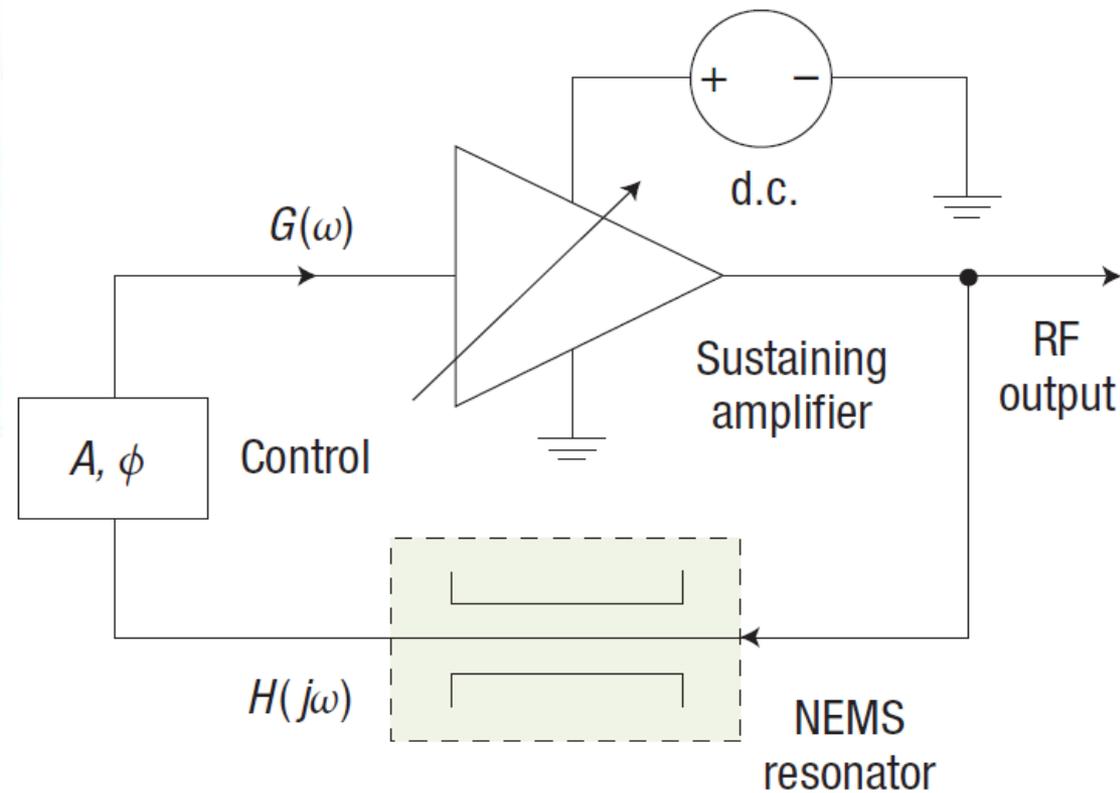
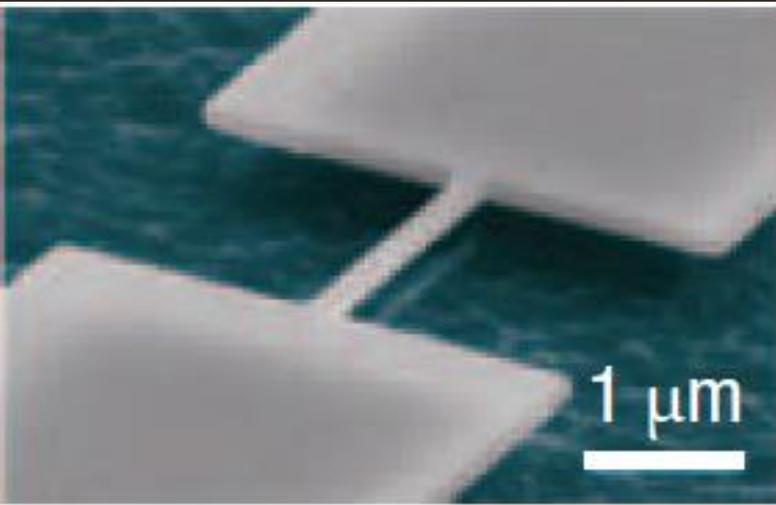
- ◎ Sensors based on nanoelectromechanical systems vibrating at high and ultrahigh frequencies
 - capable of levels of performance that surpass those of larger sensors
- ◎ NEM devices have achieved unprecedented sensitivity
 - Displacement, mass, force and charge detection
- ◎ Passive devices
 - Require external periodic or impulsive stimuli to excite them into resonance
- ◎ Novel autonomous and self-sustaining NEM oscillator
 - Generates continuous ultrahigh-frequency signals when powered by a steady d.c. source

Application of NEMS:

Self Sustaining NEM oscillator

- ◎ A self-sustaining ultra high frequency NEM oscillator
 - Frequency determining element in the oscillator is a NEM resonator
 - Embedded within a tunable electrical feedback network to generate active and stable self-oscillation
 - Excellent frequency stability
 - Linewidth narrowing and low phase noise performance

Application of NEMS: Self Sustaining NEM oscillator



Dc=source voltage to increase the ac current volatage

Amplifier is amplifying the voltage from the phase controlled current

The resonator is filtering the current, allowing for only a certain freq to go through

$H(j\omega)$ is a freq response

Control changes the phase

Application of NEMS: Self Sustaining NEM oscillator

- ⦿ Ultrahighfrequency oscillators provide a comparatively simple means for implementing a wide variety of practical sensing applications
- ⦿ Opportunities for nanomechanical frequency control, timing and synchronization

Application of NEMS: NEM Tunable Laser

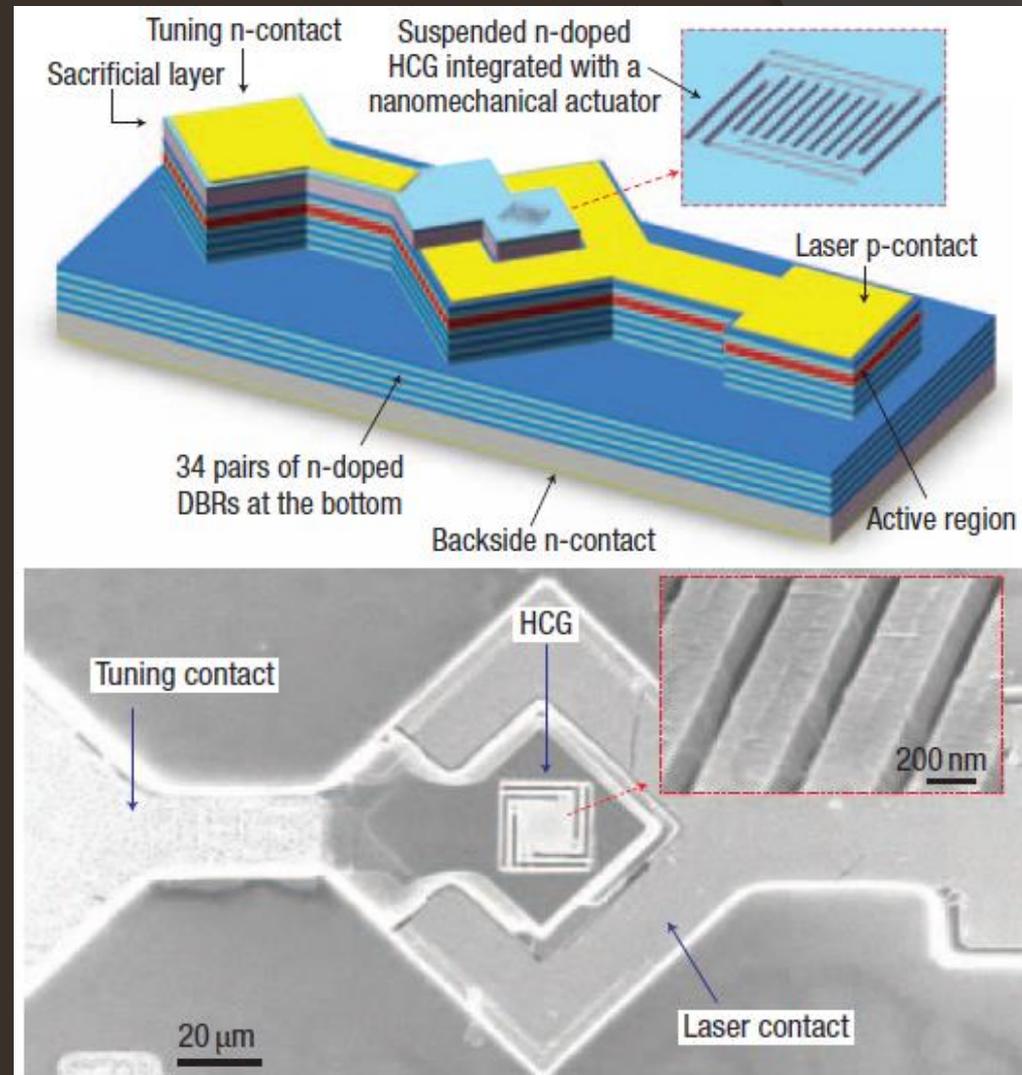
- ⊙ Tuning the frequency of an oscillator is of critical importance
 - Fundamental building block for many systems
 - Mechanical or Electronic
- ⊙ Highly inadequate in optical oscillators
 - Particularly in semiconductor laser diodes
- ⊙ Limitations in tuning a laser frequency (or wavelength)
 - include the tuning range and the speed of tuning
 - Typically milliseconds or slower
- ⊙ Tuning is often not continuous
 - Requires complex synchronization of several electrical control signals

Application of NEMS: NEM Tunable Laser

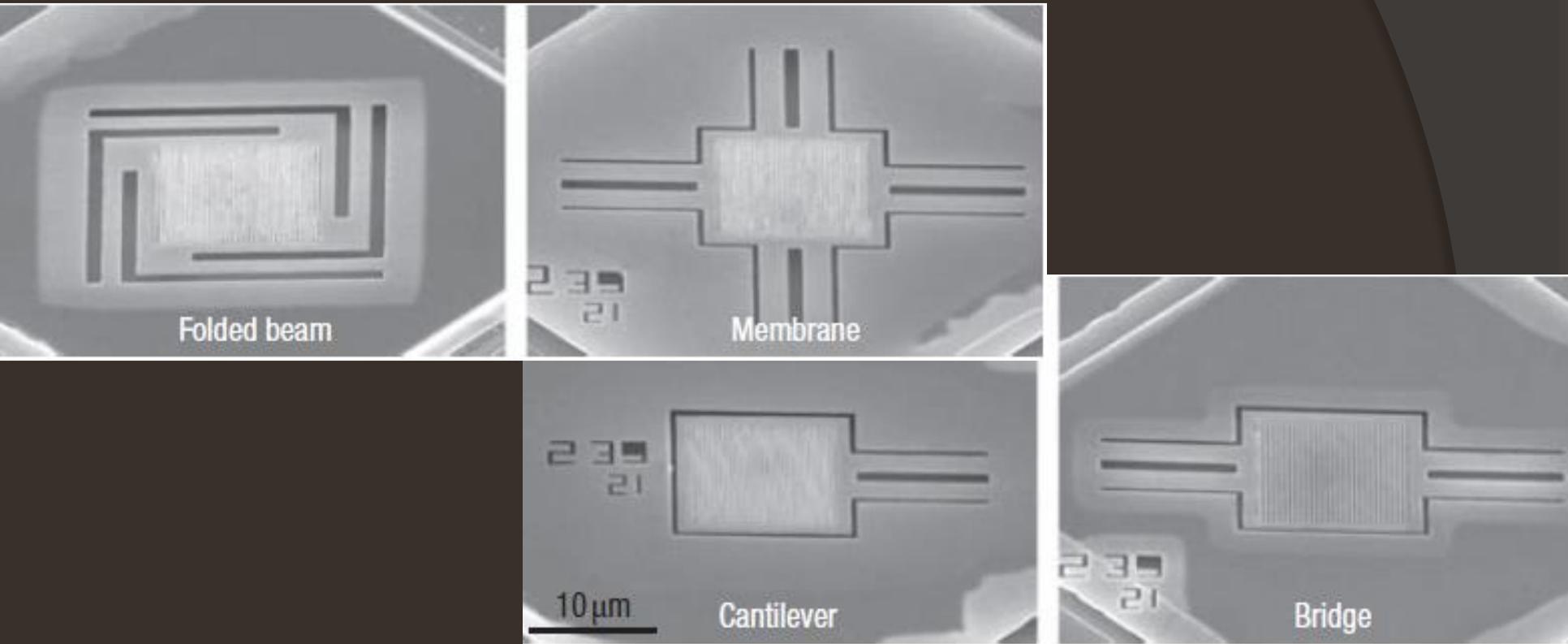
- ◎ Nanoelectromechanical Tunable Laser
 - Lightweight NEM mirror based on a single-layer, high contrast grating (HCG)
 - Enables a drastic reduction of the mirror mass
 - Increases the mechanical resonant frequency
 - Increases the tuning speed
 - Allows a wavelength-tunable light source
 - Potential switching speeds of the order of tens of nanoseconds
 - Various new areas of practical application
 - bio- or chemical sensing, chip-scale atomic clocks and projection displays

Application of NEMS: NEM Tunable Laser

- ◉ Schematic of the electrostatic-actuated NEMO-tunable VCSEL
- ◉ High Contrast Grating (HCG) is freely suspended above a variable air gap
 - Supported by a nanomechanical structure
 - cantilever
 - Bridge
 - folded beam
 - membrane



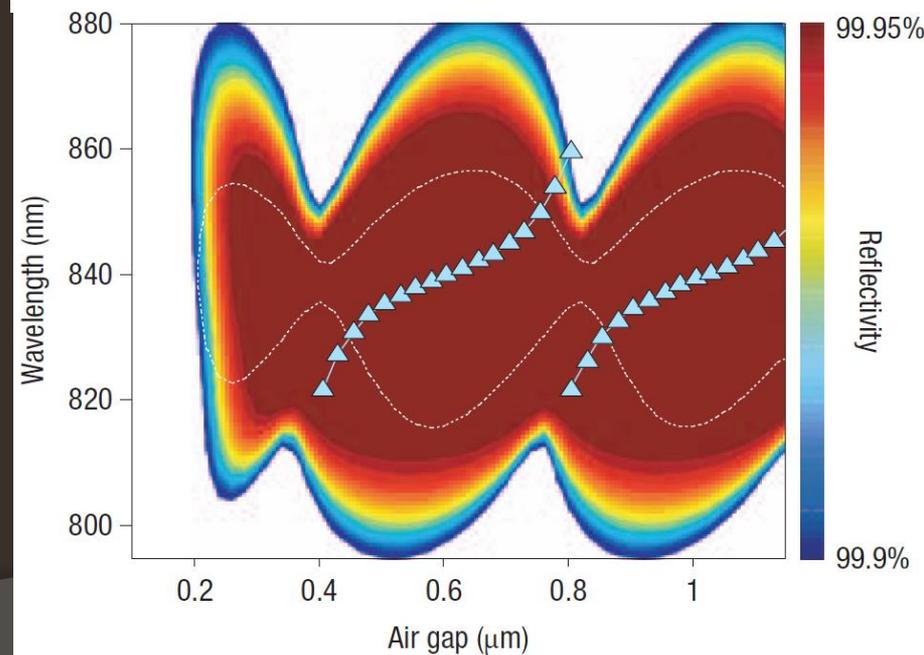
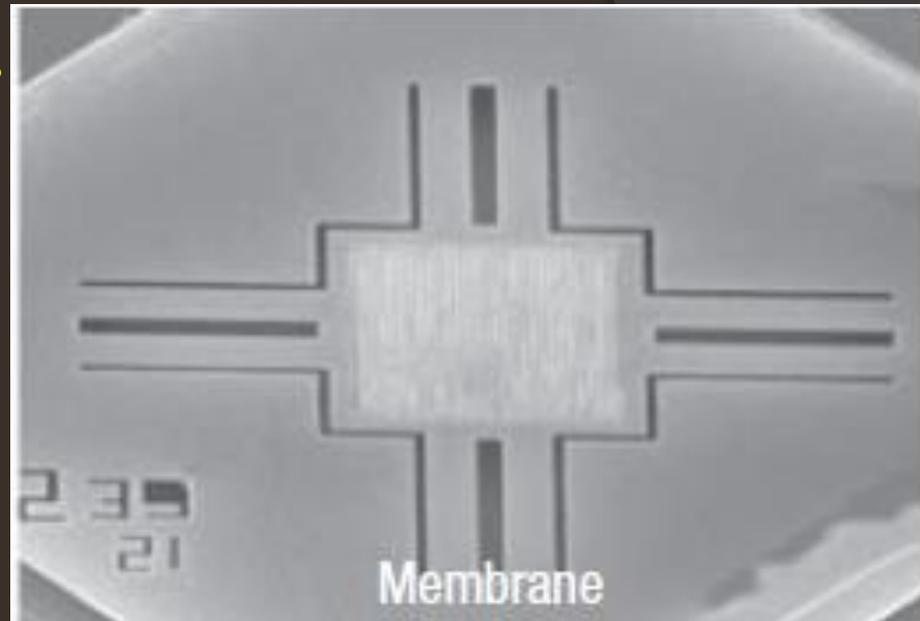
Application of NEMS: NEM Tunable Laser



- Integration of the freely suspended HCG mirror with a variety of nanomechanical actuators that can be designed for different values of mechanical stiffness

Application of NEMS: NEM Tunable Laser

- Wavelength tuning is a function of the air-gap thickness below the NEM suspended HCG
- Blue Triangle Curves
 - Calculated laser emission wavelength (Wavelength)
- Color-coded Contour
 - HCG mirror reflection bandwidth (Reflectivity)



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Conclusion

- ⦿ Nanoelectromechanical systems (NEMS) are used to measure extremely small masses and forces
- ⦿ Measurements rely on a resonator oscillating at a very stable frequency so that a small change in the resonant frequency caused by, for example, a molecule landing on the resonator, can be readily detected
- ⦿ Self-sustaining NEMS oscillators enable a wide spectrum of applications
 - Offer significant advantage over other frequency-shift detection as no source of external excitation is required
 - Yields an immense simplification of design that is crucial for next-generation, highly multiplexed sensing applications involving large arrays of devices

Conclusion

- ◎ A viable structure and fabrication process for a NEM memory cell for ultra-large-scale integrated memory applications
 - Proposed write–read scheme is similar to that of a conventional DRAM
 - Conventional sensing schemes
 - CMOS circuits
 - High integration densities due to the vertical nature of the NEM capacitor
- ◎ High-speed nanoelectromechanical tunable laser
 - Monolithically integrating a lightweight, single-layer HCG as the movable top mirror
 - results in a drastic reduction in mass
 - substantial improvement in tuning speed
 - Results in an optical mirror design for the next generation of NEMO-tunable devices

Any Questions!

**I Appreciate for Your
Attention Kindly**

www.Fooladvand.tk